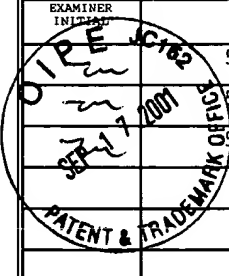




<b>Form PTO-1449</b>  <b>INFORMATION DISCLOSURE CITATION IN AN APPLICATION</b>  (Use several sheets if necessary)	<b>ATTY DOCKET NO.</b> 0459-0611P	<b>APPLICATION NO.</b> 09/867,606
	<b>APPLICANT</b> Ib JOHANNSEN, et al.	
	<b>FILING DATE</b> May 31, 2001	<b>GROUP</b> 2644

### U.S. PATENT DOCUMENTS

EXAMINER INITIALS	DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS	FILING DATE IF APPROPRIATE
	5 8 2 2 1 7 0	1998-10-13	Cabuz, et al.			
	5 6 5 8 6 9 8	1997-08-19	Yagi, et al.			
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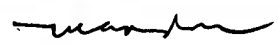
### FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS	TRANSLATION	
						YES	NO
	WO 98 1 8 8 5 5	1998-05-07	PCT				
	EP 0 8 9 9 0 9 3	1999-03-03	EUROPE				

### OTHER DOCUMENTS

(Include Name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.) date, page(s), volume-issue number(s), publisher, city and/or country where published.

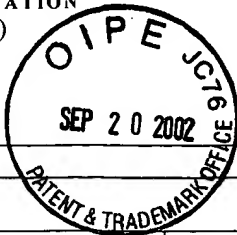
	"Anti-Stiction Hydrophobic Surfaces for Microsystems" P. Voumard, et al., CSEM Scientific and Technical Report 1998 Neuchatel, Switzerland, pg. 26
	"The Property of Plasma Polymerized Fluorocarbon Film in Relation to CH <sub>4</sub> /C <sub>4</sub> F <sub>8</sub> ratio and Substrate Temperature", Y. Matsumoto, et al., Proc. of Transducers '99, June 7-10, 1999, pp. 34-37
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	"Elimination of Post-Release Adhesion in Microstructures Using Conformal Fluorocarbon Coatings", P. F. Man, et al., Journal of Microelectromechanical Systems, Vol. 6, No. 1, March 1997, pp. 25-34
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<small>EXAMINER: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.</small>	

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Sheet 1 of 1



ATTORNEY DOCKET NO.	SERIAL NO.
45900-000611/US	09/867,606
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FILING DATE	GROUP
May 31, 2001	2644

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	<i>m</i>	3,963,881	06/15/1976	Fraim et al.	179/111	05/29/1973
	<i>m</i>	5,812,496	9/22/1998	Peck	367/174	10/20/1997
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	<i>m</i>	WO 93/04495	03/04/1993	WIPO			
	<i>m</i>	EP 0849082A2	12/19/1997	Europe			

OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)

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